L Number	Hits	Search Text	DB	Time stamp
3	37	(((wafer or semiconductor) and (pedestal	USPAT;	2003/11/18 10:02
-		same vertical\$4) and (mult\$4 near5	US-PGPUB	
		chamber\$2)) and deposition) and chuck and		
		heater		
4	25	5909994.URPN.	USPAT	2003/11/18 09:55
5	58	(wafer or semiconductor) and vertical and	USPAT;	2003/11/18 10:03
		multichamber and deposition and chuck and	US-PGPUB	
		heater		
6	66	(wafer or semiconductor) and vertical and	USPAT;	2003/11/18 10:03
_		multichamber and deposition and chuck	US-PGPUB	
7	201	(wafer or semiconductor) and vertical and	USPAT;	2003/11/18 10:03
	170	multichamber and deposition	US-PGPUB	0000 (11 (10 10 04
8	172	((wafer or semiconductor) and vertical and	USPAT;	2003/11/18 10:04
		multichamber and deposition) and (pedestal	US-PGPUB	
9	11	or support) (((wafer or semiconductor) and vertical	HCDAM.	2002/11/10 10:05
9	11	and multichamber and deposition) and	USPAT; US-PGPUB	2003/11/18 10:05
		(pedestal or support)) and 700/\$.ccls.	US-FGFUB	
12	2	6178660.URPN.	USPAT	2003/11/18 10:12
13	13	("4795299" "4917556" "5228206"	USPAT	2003/11/18 10:12
10	13	"5423971" "5529657" "5611861"	001711	2003/11/10 10.13
		"5755938" "5759334" "5855675"		
		"5863170" "5880924" "5882165"		
		"5886864").PN.		
14	1	4423701.pn.	USPAT;	2003/11/18 10:23
		-	US-PGPUB	
15	1	4423701.pn. and vertical	USPAT;	2003/11/18 10:23
			US-PGPUB	
16	15	,	USPAT;	2003/11/18 10:40
		US-5518542-\$ or US-4664939-\$ or	US-PGPUB	
		US-6524952-\$ or US-6387185-\$ or		
		US-5916365-\$ or US-6143086-\$ or		
		US-6497767-\$ or US-6178660-\$ or		
		US-5772773-\$ or US-6318945-\$).did. or		
		(US-20020056414-\$ or US-20020197863-\$ or		
17	51	US-20020076490-\$).did.	HCDAM.	2002/11/10 10:45
1 '	21	multizone and deposition and wafer	USPAT; US-PGPUB	2003/11/18 10:45
18	25	(multizone and deposition and wafer) and	USPAT;	2003/11/18 10:40
	23	vertical	US-PGPUB	2003/11/10 10.40
19	4	((multizone and deposition and wafer) and	USPAT;	2003/11/18 10:42
	_	vertical) and pedestal	US-PGPUB	2000, 22, 20 20, 12
20	1	6352593.pn.	USPAT;	2003/11/18 10:42
			US-PGPUB	
21	220	(multizone or multi-zone) and deposition	USPAT;	2003/11/18 10:46
		and wafer	US-PGPUB	
22	0	((multizone or multi-zone) and deposition	USPAT;	2003/11/18 10:46
		and wafer) and verticle	US-PGPUB	
23	126	((multizone or multi-zone) and deposition	USPAT;	2003/11/18 10:46
		and wafer) and vertical	US-PGPUB	
24	104	(((multizone or multi-zone) and deposition	USPAT;	2003/11/18 10:46
		and wafer) and vertical) and (support or	US-PGPUB	
25		pedestal)		0000/65/55
25	63	((((multizone or multi-zone) and	USPAT;	2003/11/18 10:46
		deposition and wafer) and vertical) and	US-PGPUB	
26	0.7	(support or pedestal)) and heater		0000/11/10 11 15
26	27		USPAT;	2003/11/18 11:12
		deposition and wafer) and vertical) and	US-PGPUB	
		(support or pedestal)) and heater) and chuck		
27	2	6413321.URPN.	HCDAM	2002/11/10 10:50
28	17	("3627590" "4798165" "5045346"	USPAT	2003/11/18 10:50 2003/11/18 10:50
- 0	ļ , , , , , , , , , , , , , , , , , , ,	"5221414" "5230741" "5238499"	USPAT	2003/11/18 10:50
		3221414		
		3244730	1	
		"5614055" "5855681" "5871811"		1
		"5879128" "6020035").PN.		
29	1329	118/719.ccls.	USPAT;	2003/11/18 11:12
			US-PGPUB	2005/11/10 11.12
		1	LOG LGEOD	1

30	73	118/719.ccls. and pedestal and vertical	USPAT; US-PGPUB	2003/11/18 12:47
31	450	118/719.ccls. and (pedestal or support) and vertical	USPAT; US-PGPUB	2003/11/18 11:13
32	25		USPAT; US-PGPUB	2003/11/18 12:55
33	253	118/719.ccls. and aperture	USPAT; US-PGPUB	2003/11/18 12:55
34	171	(118/719.ccls. and aperture) and vertical\$3	USPAT; US-PGPUB	2003/11/18 12:55
35	112	((118/719.ccls. and aperture) and vertical\$3) and wafer	USPAT; US-PGPUB	2003/11/18 12:55
36	56	(((118/719.ccls. and aperture) and vertical\$3) and wafer) and (region or zone)	USPAT; US-PGPUB	2003/11/18 12:57
37	3	((((118/719.ccls. and aperture) and vertical\$3) and wafer) and (region or zone)) and piston	USPAT; US-PGPUB	2003/11/18 13:26
38	30		HCDAT	2002/11/10 12.12
39	823		USPAT;	2003/11/18 13:13 2003/11/18 13:27
40	257	700/121.ccls. and deposition and wafer	US-PGPUB USPAT; US-PGPUB	2003/11/18 13:27
41	11	(700/121.ccls. and deposition and wafer) and zone and aperture	USPAT; US-PGPUB	2003/11/18 13:27
42	44138	438/\$.ccls. and deposition	USPAT; US-PGPUB	2003/11/18 13:30
43	12	(438/\$.ccls. and deposition) and pedestal and piston	USPAT; US-PGPUB	2003/11/18 13:34
44	607	438/680.ccls.	USPAT; US-PGPUB	2003/11/18 13:36
45	10	deposition and wafer adj support and (multizone or multi-zone) and aperture and vertical\$4 and heat\$4	USPAT; US-PGPUB	2003/11/18 13:39
46	4	cvd and pedestal same piston	USPAT; US-PGPUB	2003/11/18 13:48
47	17	("4382739" "4513855" "4590380" "4619573" "4632624" "4746256" "4801241" "4861222" "4872947" "4894132" "4902531" "4915564" "4923584" "5051054" "5098198" "5108570" "5131460").PN.	USPAT	2003/11/18 13:40
48	607	438/680.ccls.	USPAT; US-PGPUB	2003/11/18 13:48
49	26	438/680.ccls. and wafer adj support	USPAT; US-PGPUB	2003/11/18 14:04
50	25	438/680.ccls. and vertical and pedestal	USPAT; US-PGPUB	2003/11/18 14:04
51	19	(438/680.ccls. and vertical and pedestal) not (438/680.ccls. and wafer adj support)	USPAT; US-PGPUB	2003/11/18 14:09
52	8	("4951601" "5246881" "5366585" "5516367" "5558717" "5846332" "5853607" "5885356").PN.	USPAT	2003/11/18 14:06
53 54	2 323	6063441.URPN. 438/478.ccls.	USPAT;	2003/11/18 14:08 2003/11/18 14:09
55	14	438/478.ccls. and pedestal	US-PGPUB USPAT; US-PGPUB	2003/11/18 14:12
56	690	wafer and deposition and support same screw and vertical	USPAT; US-PGPUB	2003/11/18 14:12
57	245	(wafer and deposition and support same screw and vertical) and cvd	USPAT; US-PGPUB	2003/11/18 14:12
58	123	((wafer and deposition and support same screw and vertical) and cvd) and heater	USPAT; US-PGPUB	2003/11/18 14:13
59	47	(((wafer and deposition and support same screw and vertical) and cvd) and heater) and zone	USPAT; US-PGPUB	2003/11/18 14:20
61	24	5620523.URPN.	USPAT	2003/11/18 14:20
60	38	deposition and wafer and ball adj screw and zone	USPAT;	2003/11/18 14:31
L	L	and Zone	US-PGPUB	

62	275	cvd and ball adj screw	USPAT; US-PGPUB	2003/11/18 14:31
63	6	(cvd and ball adj screw) and zone and aperture	USPAT; US-PGPUB	2003/11/18 14:31
73	0	6497767.URPN.	USPAT	2003/11/18 15:14
74	10	("5273588" "5418885" "5446825" "5688331" "5796074" "5855675" "5916370" "6001183" "6190113"	USPAT	2003/11/18 15:15
		"6190460").PN.		
75	1	6497767.pn.	USPAT; US-PGPUB	2003/11/18 16:30
76	1	6650315.pn.	USPAT; US-PGPUB	2003/11/18 16:49
77	1	6650346.pn.	USPAT; US-PGPUB	2003/11/18 16:50
_	498	atomic adj layer adj deposition	USPAT; US-PGPUB	2003/07/28 11:14
_	194	(atomic adj layer adj deposition) and chamber and region\$1	USPAT; US-PGPUB	2003/02/27 15:50
_	94	((atomic adj layer adj deposition) and chamber and region\$1) and @ad<=20010727	USPAT; US-PGPUB	2003/02/27 16:43
-	67	(((atomic adj layer adj deposition) and chamber and region\$1) and @ad<=20010727) and wafer	USPAT; US-PGPUB	2003/02/27 15:51
_	16		USPAT; US-PGPUB	2003/02/27 15:51
_	12		USPAT; US-PGPUB	2003/02/27 16:01
-	1	5951776.pn.	USPAT; US-PGPUB	2003/02/27 16:06
-	1	6525747.pn.	USPAT; US-PGPUB	2003/02/27 16:40
_	1	"6174805".PN.	USPAT; US-PGPUB	2003/02/27 16:36
-	1	"6132514".PN.	USPAT; US-PGPUB	2003/02/27 16:36
_	1	"6071552".PN.	USPAT; US-PGPUB	2003/02/27 16:37
-	1	"5998871".PN.	USPAT; US-PGPUB	2003/02/27 16:37
	1	"5998871".PN.	USPAT; US-PGPUB	2003/02/27 16:37
_	1	"5972785".PN.	USPAT; US-PGPUB	2003/02/27 16:37
	1	"5916365".PN.	USPAT; US-PGPUB	2003/02/27 16:37
_	1	"5416045".PN. "5344792".PN.	USPAT; US-PGPUB	2003/02/27 16:38
_	1	"6190732".PN.	USPAT; US-PGPUB USPAT;	2003/02/27 16:38
_	1	"6174377".PN.	US-PGPUB USPAT;	2003/02/27 16:39
_	1	"5935338".PN.	US-PGPUB USPAT;	2003/02/27 16:40
_	1	"5879459".PN.	US-PGPUB USPAT;	2003/02/27 16:40
_	1	"5582866".PN.	US-PGPUB USPAT;	2003/02/27 16:40
_	655	700/121.ccls.	US-PGPUB USPAT;	2003/02/27 16:40
_	213	700/121.ccls. and deposition	US-PGPUB USPAT;	2003/02/27 16:41
_	113	(700/121.ccls. and deposition) and chamber	US-PGPUB USPAT;	2003/02/27 16:41
_	90	((700/121.ccls. and deposition) and chamber) and @ad<=20010727	US-PGPUB USPAT; US-PGPUB	2003/03/03 14:47

Page 3

-	3	(((700/121.ccls. and deposition) and chamber) and @ad<=20010727) and piston	USPAT; US-PGPUB	2003/02/27 16:41
_	1	(((atomic adj layer adj deposition) and chamber and region\$1) and @ad<=20010727) and piston	USPAT; US-PGPUB	2003/02/27 16:50
-	1228	118/719.ccls.	USPAT; US-PGPUB	2003/02/27 16:50
-	55	118/719.ccls. and wafer and piston	USPAT; US-PGPUB	2003/02/27 16:50
-	16	(118/719.ccls. and wafer and piston) and aperture	USPAT; US-PGPUB	2003/02/27 16:51
-	15	kosowski.xa.	USPAT; US-PGPUB	2003/03/03 14:05
_	4183	deposition and wafer and support and chamber and region\$2 and temperature and two and gas	USPAT; US-PGPUB	2003/03/03 14:47
_	3626	(deposition and wafer and support and chamber and region\$2 and temperature and	USPAT; US-PGPUB	2003/03/03 17:34
-	167	two and gas) and @ad<=20010727 ((deposition and wafer and support and chamber and region\$2 and temperature and	USPAT; US-PGPUB	2003/03/03 14:50
_	11	two and gas) and @ad<=20010727) and piston (((deposition and wafer and support and chamber and region\$2 and temperature and two and gas) and @ad<=20010727) and	USPAT; US-PGPUB	2003/03/03 14:51
_	90	piston) and monolayer ((deposition and wafer and support and chamber and region\$2 and temperature and two and gas) and @ad<=20010727) and atomic adj layer	USPAT; US-PGPUB	2003/03/03 14:51
_	1413684	(((deposition and wafer and support and chamber and region\$2 and temperature and two and gas) and @ad<=20010727) and atomic	USPAT; US-PGPUB	2003/03/03 14:53
-	90	adj layer) and deposition near\$5 region\$1 (((deposition and wafer and support and chamber and region\$2 and temperature and two and gas) and @ad<=20010727) and atomic adj layer) and (deposition near\$5	USPAT; US-PGPUB	2003/03/03 16:18
_	1	region\$1) "6174805".PN.	USPAT; US-PGPUB	2003/03/03 15:11
-	1	"6132514".PN.	USPAT; US-PGPUB	2003/03/03 15:11
-	1	"6071552".PN.	USPAT; US-PGPUB	2003/03/03 15:11
_	1	"5998871".PN.	USPAT; US-PGPUB	2003/03/03 15:11
. –	4	((deposition and wafer and support and chamber and region\$2 and temperature and two and gas) and @ad<=20010727) and	USPAT; US-PGPUB	2003/03/03 16:35
-	64	moveable adj support deposition and moveable adj support	USPAT; US-PGPUB	2003/03/03 16:35
-	62	(deposition and moveable adj support) and @ad<=20010727	USPAT; US-PGPUB	2003/03/03 16:37
_	25	((deposition and moveable adj support) and @ad<=20010727) and wafer	USPAT; US-PGPUB	2003/03/03 17:16
-	1	"5013400".PN.	USPAT; US-PGPUB	2003/03/03 16:45
-	1	"4990374".PN.	USPAT; US-PGPUB	2003/03/03 16:45
_	1	"4978412".PN.	USPAT; US-PGPUB	2003/03/03 16:46
-	1	"4963713".PN.	USPAT; US-PGPUB	2003/03/03 16:46
-	655	700/121.ccls.	USPAT; US-PGPUB	2003/03/03 17:16
-	2	700/121.ccls. and atomic adj layer adj deposition	USPAT; US-PGPUB	2003/03/03 17:33
-	21	interconnected with deposition with region\$2	USPAT; US-PGPUB	2003/03/03 17:33

Page 4

_	21	(interconnected with deposition with	USPAT;	2003/03/04 10:10
_	1	region\$2) and @ad<=20010727 4423701.pn.	US-PGPUB USPAT;	2003/03/04 10:10
_	1	4423701.pn. and (heater or temperature)	US-PGPUB USPAT;	2003/03/04 11:13
_	9	(US-6524952-\$ or US-6387185-\$ or	US-PGPUB USPAT;	2003/03/04 13:26
		US-5916365-\$ or US-5292554-\$ or US-4423701-\$ or US-4664939-\$).did. or (US-20020197863-\$ or US-20020076490-\$ or	US-PGPUB	
- .	2	US-20020056414-\$).did. ((US-6524952-\$ or US-6387185-\$ or US-5916365-\$ or US-5292554-\$ or US-4423701-\$ or US-4664939-\$).did. or (US-20020197863-\$ or US-20020076490-\$ or	USPAT; US-PGPUB	2003/03/04 13:51
-	0	US-20020056414-\$).did.) and aperture 4423701.pn. and gase	USPAT;	2003/03/04 13:51
_	1	4423701.pn. and gas	US-PGPUB USPAT; US-PGPUB	2003/03/04 13:51
_	1	4664939.pn. and gas	USPAT; US-PGPUB	2003/03/04 14:09
_	2	((US-6524952-\$ or US-6387185-\$ or US-5916365-\$ or US-5292554-\$ or	USPAT; US-PGPUB	2003/03/04 14:18
-	0	US-4423701-\$ or US-4664939-\$).did. or (US-20020197863-\$ or US-20020076490-\$ or US-20020056414-\$).did.) and electrostatic ((US-6524952-\$ or US-6387185-\$ or US-5916365-\$ or US-5292554-\$ or US-4423701-\$ or US-4664939-\$).did. or (US-20020197863-\$ or US-20020076490-\$ or US-20020056414-\$).did.) and piston	USPAT; US-PGPUB	2003/03/04 14:18
_	18	atomic adj layer adj deposition and piston	USPAT; US-PGPUB	2003/03/04 14:22
_	437	deposition and chamber and support and wafer and piston	USPAT; US-PGPUB	2003/03/04 14:23
-	242	(deposition and chamber and support and wafer and piston) and region and gas	USPAT; US-PGPUB	2003/03/04 14:23
_	191	((deposition and chamber and support and wafer and piston) and region and gas) and @ad<=20010727	USPAT; US-PGPUB	2003/03/04 14:25
-	94	deposition and wafer adj support and piston	USPAT; US-PGPUB	2003/03/04 14:25
_	83	(deposition and wafer adj support and piston) and @ad<=20010727	USPAT; US-PGPUB	2003/03/04 14:26
_	8	((deposition and wafer adj support and piston) and @ad<=20010727) and wafer adj support with piston	USPAT; US-PGPUB	2003/03/04 14:28
-	1	5228502.pn.	USPAT; US-PGPUB	2003/03/04 14:28
-	10	(US-6524952-\$ or US-6387185-\$ or US-5916365-\$ or US-5292554-\$ or US-4664939-\$ or US-4423701-\$ or US-5518542-\$).did. or (US-20020076490-\$ or	USPAT; US-PGPUB	2003/07/25 14:05
_	1	US-20020197863-\$ or US-20020056414-\$).did. ((US-6524952-\$ or US-6387185-\$ or US-5916365-\$ or US-5292554-\$ or US-4664939-\$ or US-4423701-\$ or	USPAT; US-PGPUB	2003/07/25 14:06
-	8	US-5518542-\$).did. or (US-20020076490-\$ or US-20020197863-\$ or US-20020056414-\$).did.) and elevation ((US-6524952-\$ or US-6387185-\$ or US-5916365-\$ or US-5292554-\$ or US-4664939-\$ or US-4423701-\$ or US-5518542-\$).did. or (US-20020076490-\$ or US-20020197863-\$ or	USPAT; US-PGPUB	2003/07/25 14:11
-	58	US-20020056414-\$).did.) and vertical dworkin.in.	USPAT;	2003/07/28 11:14
_	1	dworkin.in. and vendor	US-PGPUB USPAT; US-PGPUB	2003/07/28 11:56

_	20721	image adj planes	USPAT;	2003/07/28 11:56
	20721	Image adj planes	US-PGPUB	2003, 0,,20 11.30
_	1159	(image adj planes) and 345/\$.ccls.	USPAT;	2003/07/28 11:56
	1133	(Image da) planes, and sie, (1001)	US-PGPUB	
_	680	118/729.ccls.	USPAT;	2003/11/17 16:10
		110, 113, 0013,	US-PGPUB	
_	411	118/729.ccls. and (vertical or elevation)	USPAT;	2003/11/17 16:10
		(10000000000000000000000000000000000000	US-PGPUB	
_	306	(118/729.ccls. and (vertical or	USPAT;	2003/11/17 16:10
		elevation)) and deposition	US-PGPUB	
_	50		USPAT;	2003/11/17 16:10
		elevation)) and deposition) and chuck	US-PGPUB	
-	48	(((118/729.ccls. and (vertical or	USPAT;	2003/11/17 16:11
		elevation)) and deposition) and chuck) and	US-PGPUB	
		(zone or chamber)	1	
-	12		USPAT;	2003/11/17 16:16
		elevation)) and deposition) and chuck) and	US-PGPUB	
		(zone or chamber)) and pedestal		1
-	9	(((((120)))))	USPAT;	2003/11/17 16:19
		elevation)) and deposition) and chuck) and	US-PGPUB	
		(zone or chamber)) and pedestal) and		
		(((118/729.ccls. and (vertical or	1	
		elevation)) and deposition) and (pedestal	-	
		same vertical\$3))	j	
-	32		USPAT;	2003/11/17 16:50
		elevation)) and deposition) and (pedestal	US-PGPUB	
		same vertical\$3)		
-	1	1	USPAT	2003/11/17 16:27
-	16		USPAT	2003/11/17 16:27
		"4938815" "5065698" "5094885"		
		"5135629" "5169684" "5192371"		
}		"5213650" "5228501" "5238499"		
		"5304249" "5474612" "5589224"		
ļ	005	"5803977").PN.	TIODAM.	2002/11/17 16 51
-	225		USPAT; US-PGPUB	2003/11/17 16:51
		same vertical\$4) and (mult\$4 near5 chamber\$2)	05-FGF0B	
_	209		USPAT;	2003/11/17 16:51
-	209	same vertical\$4) and (mult\$4 near5	US-PGPUB	2003/11/1/ 18:51
1		chamber\$2)) and deposition	03-16100	
_	16		USPAT	2003/11/17 16:52
_	1 70	1 3033073. UKEN.	OSEMI	5000/II/I/ I0:05